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Г	APPLICATION NO.	FILING DATE		FIRST NAMED IN	ENTOR		ATTORNEY DOCKET NO.	
_	08/893,91	7 07/11/	97	LITTAU		К	AM2119/T2130	
Г				IM62/0617	コ		EXAMINER	
		ATERIALS II UNSEL MS 2		at Foundary Contract		ZER\ ART UNIT	VIGON, R PAPER NUMBER	
	LEGAL AFF PO BOX 45					1763	b	
	SANTA CLA	RA CA 9505	2			DATE MAILED):	

Please find below and/or attached an Office communication concerning this application or proceeding.

Commissioner of Patents and Trademarks

06/17/99

Office Action Summary

Application No. 08/893,917 Applicant(s)

Littau et al

Examiner

Group Art Unit

	Rudy Zervigon	1763	
☐ Responsive to communication(s) filed on			
☐ This action is FINAL.			
☐ Since this application is in condition for allowance except in accordance with the practice under <i>Ex parte Quayle</i> ,		n as to the me	erits is closed
A shortened statutory period for response to this action is a is longer, from the mailing date of this communication. Fail application to become abandoned. (35 U.S.C. § 133). Ext 37 CFR 1.136(a).	ure to respond within the period	for response	will cause the
Disposition of Claims			
	is/are p	ending in the	application.
Of the above, claim(s)	is/are wi	thdrawn from	consideration.
Claim(s)	is	/are allowed.	
Claim(s)	is	/are rejected.	
Claim(s)	is	/are objected t	to.
X Claims <u>1-20</u>	are subject to restricti	on or election	requirement.
Application Papers See the attached Notice of Draftsperson's Patent Dra The drawing(s) filed on is/are of The proposed drawing correction, filed on The specification is objected to by the Examiner. The oath or declaration is objected to by the Examine Priority under 35 U.S.C. § 119 Acknowledgement is made of a claim for foreign prio All Some* None of the CERTIFIED copie received. received in Application No. (Series Code/Serial received in this national stage application from *Certified copies not received:	is bpproved r. rity under 35 U.S.C. § 119(a)-(ces of the priority documents have been been been been been been been be	e been ule 17.2(a)).	
Acknowledgement is made of a claim for domestic pr	iority under 35 U.S.C. § 119(e)	•	
Attachment(s) Notice of References Cited, PTO-892 Information Disclosure Statement(s), PTO-1449, Paper Interview Summary, PTO-413 Notice of Draftsperson's Patent Drawing Review, PTO Notice of Informal Patent Application, PTO-152			
SEE OFFICE ACTION O	ON THE FOLLOWING PAGES		

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DETAILED ACTION

Election/Restriction

- 1. Restriction to one of the following inventions is required under 35 U.S.C. 121:
 - I. Claims 1-7, drawn to a method for removing residue from a substrate processing chamber, classified in class 117, subclass *97.
 - II. Claims 8-15, drawn to a deposition device, classified in class 438, subclass 485.
 - III. Claims 16-20, drawn to a substrate processing system, classified in class 364, subclass 528.01.
- 2. The inventions are distinct, each from the other because of the following reasons: Inventions I and II are related as process and apparatus for its practice. The inventions are distinct if it can be shown that either: (1) the process as claimed can be practiced by another materially different apparatus or by hand, or (2) the apparatus as claimed can be used to practice another and materially different process. (MPEP § 806.05(e)). In this case the deposition device can be used to practice another materially different process, namely a subtractive process as claimed in invention I.
- 3. Inventions I and III are unrelated. Inventions are unrelated if it can be shown that they are not disclosed as capable of use together, or they have different modes of operation, or they have different functions, or they have different effects. (MPEP § 806.04, MPEP § 808.01). In the instant case the different inventions have different effects. Specifically, invention I is claimed as an invention

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for removing residue from a substrate processing chamber while invention III is claimed as a control

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system for controlling the process/method claimed in invention I.

4. Because these inventions are distinct for the reasons given above and have acquired a separate

status in the art as shown by their different classification, restriction for examination purposes as

indicated is proper.

5. Because these inventions are distinct for the reasons given above and have acquired a separate

status in the art as shown by their different classification, restriction for examination purposes as

indicated is proper.

6. A telephone call was made to Ken Brooks on June 11, 1999 to request an oral election to the

above restriction requirement, but did not result in an election being made.

Applicant is advised that the reply to this requirement to be complete must include an election

of the invention to be examined even though the requirement be traversed (37 CFR 1.143).

7. Applicant is reminded that upon the cancellation of claims to a non-elected invention, the

inventorship must be amended in compliance with 37 CFR 1.48(b) if one or more of the currently

named inventors is no longer an inventor of at least one claim remaining in the application. Any

amendment of inventorship must be accompanied by a petition under 37 CFR 1.48(b) and by the fee

required under 37 CFR 1.17(i).

Any inquiry concerning this communication or earlier communications from the examiner 8.

should be directed to Examiner Rudy Zervigon whose telephone number is (703) 305-1351. The

examiner can normally be reached on a Monday through Friday schedule from 8am until 5pm. The

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official AF fax phone number for the 1763 art unit is (703) 305-3599. Any Inquiry of a general nature

or relating to the status of this application or proceeding should be directed to the Chemical and

Materials Engineering art unit receptionist at (703) 308-0661.

Bruce Breneman Supervisory Patent Examiner Technology Center 1700 Page 4